

# DM2700P/J105 LOW TEMPERATURE

SEALING GLASS PASTE

## **PRODUCT DATA SHEET**

### I. DESCRIPTION

UNIMEC DM2700P/J105 sealing glass paste is designed to hermetically seal low thermal expansion materials such as silicon, alumina, Kovar, borosilicate and soda lime glasses at temperatures as low as 320 °C. UNIMEC DM2700P/J105 is a fine particle-sized sealing glass paste. It allows for thinner, uniform bondline thicknesses in certain applications. The paste comprises a low temperature glass powder loaded in a unique organic system which burns out completely during glazing.

UNIMEC DM2700P/J105 paste can be screen-printed, stencil-printed or dispensed. It is glazed to the substrate at 350 °C. The glazed surface is mated to the other component under slight pressure and fired at a peak temperature ranging from 320 to 375 °C for as little as 2 minutes to achieve a reliable, hermetic seal.

## II. KEY FEATURES

- O Very fast processing as little as one minute as glazed film
- O Hermetic seals achieved at temperatures as low as 320°C
- O Low thermal expansion matched to alumina
- O High adhesion to most surfaces, including gold
- O Proprietary, clean burning organic system
- O Excellent rheology for screen printing or dispensing
- O Twelve month shelf life at room temperature

## III. APPLICATIONS

UNIMEC DM2700P/J105 is designed for low temperature hermetic sealing of ceramic, glass, semiconductor and metal parts. Applications include:

- O Wafer bonding for wafer-level packaging (WLP) of MEMS and other devices
- O Attaching Kovar and ceramic lids to packages
- Attaching glass and quartz windows to packages
- Attaching lenses to optical assemblies

## IV. TYPICAL PROPERTIES

Parameter	Value	Unit	Note / Condition	
Pa	ste Properties (befo	re glazing)		
Appearance	Opaque green			
Particle size	TBD	microns	Average	
	TBD	microns	Median	
	20	microns	Maximum	
Density	4.0	g/cc		
Solids content	85.5 to 88.0	%		
Viscosity	70,000 to 110,000	centipoise	25°C, 10 rpm, Brookfield RVT viscometer	
Thixotropic index	3.4		10 / 50 rpm, 25 °C	
Shelf life	12	months	25 °C. See Storage guidelines	
	Dispensing / Pri	nting		
Screen mesh size	80 to 230			
Line thickness (wet)	5 ± 2	mils		
	125 ± 50	microns		
Aspect ratio, width to thickness	3		Minimum	
	4.5 or greater		Preferred	
Interlaver Di	rying (not needed for	single-laver pr	rintina)	
Drying temperature	100	°C	- <b>J</b>	
Drying time	10 to 15	minutes		
	Organic Burno	out		
Temperature ramp rate	≤ 5	°C/minute	Room temp to peak temp.	
			See Figure 1	
Peak dwell temperature	250	°C	See Figure 1	
Dwell time at peak temperature	30 to 60	minutes	See Figure 1	
ł ł	Glazing			
Temperature ramp rate	30 to 60	°C/minute	Room temp to peak temp. See Figure 1	
Peak dwell temperature	350 +/- 5	°C	See Figure 1	
Dwell time at peak temperature	1	minute	See Figure 1	
Line thickness (after glazing)	2 to 5	mils	_	
	50 to 125	microns		

## **TYPICAL PROPERTIES (continued)**

Parameter	Value	Unit	Note / Condition					
Sealing								
Temperature ramp rate	50	°C/minute	Minimum					
	100 or greater	°C/minute	Preferred					
Peak dwell temperature	320 to 375	°C	See Table 1, Figure 2					
Dwell time at peak temperature	2 to 10	minutes	See Table 1, Figure 2					
Pressure	3 to 6	psi	Applied to paste area					
	21 to 41	kPa						
Glass Properties (after sealing)								
Appearance	Opaque brown							
Adhesion, shear	1,700	psi	0.25" Si to alumina					
	11.7	MPa	6.35 mm Si to alumina					
Modulus	6.33 x 10 <sup>5</sup>	kg/cm <sup>2</sup>						
Softening temperature	275 to 285	°C	DTA – Differential Thermal Analysis					
Glass transition temperature (Tg)	215	°C						
Coefficient of Thermal Expansion (CTE)	7.7	ppm/°C	25 to 150 °C					
Density	7.6	g/cc						
Helium leak rate, MIL-STD-883F, Method 1014	<10 <sup>-8</sup>	atm-cc/sec	With suitable seal design					
Dielectric constant	71		1 MHz, 25 °C					
Volume resistivity	>10 <sup>9</sup>	Ω-cm	50 °C					

## V. STORAGE AND HANDLING

Store UNIMEC DM2700P/J105 in a cool, dry place away from direct sunlight. It does not require cold storage. The paste jar lid must be securely fastened to prevent solvent leakage or evaporation.

If UNIMEC DM2700P/J105 is allowed to stand for a long time, ingredients may settle out. Prior to use, mix completely but gently until the paste is uniform, avoiding entrapping air. You may use a square-tipped metal spatula or stirrer such as the Fisher Scientific model 14-375-20. Jars of UNIMEC DM2700P/J105 should not be excessively mixed nor continuously rolled, as doing so may affect its viscosity.

UNIMEC DM2700P/J105 is supplied ready to use. Thinning is not recommended. Contact Namics for information on replacing solvent in case it is lost through evaporation.

#### VI. PROCESSING GUIDELINES

UNIMEC DM2700P/J105 paste can be screen-printed, stencil-printed, or dispensed. It is then dried and glazed to the substrate at 350 °C. The glazed component is mated to the other component under slight pressure and fired at a peak temperature ranging from 320 to 375 °C for as little as 2 minutes to achieve a reliable, hermetic seal.

Please refer to section IV, Typical Properties, above and the graphs and table below.

Depending on line width and thickness, paste may be dispensed or printed in one pass. Sometimes, a second layer must be printed over a first layer. In this case, the first layer printed must be dried before printing the second layer. A typical drying profile is 10 minutes at 100 °C.

UNIMEC DM2700P/J105 requires an organic burn-out (OBO) step before glazing. The product being glazed may return to room temperature between OBO and glazing, but the preferred process is to transfer directly from OBO to glazing, as shown in Figure 1.

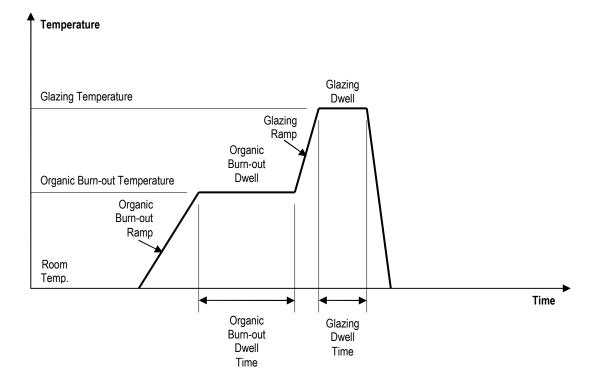
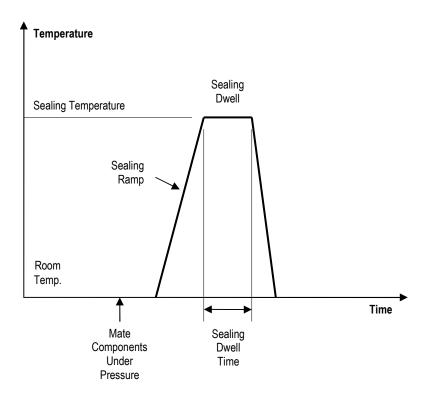


Figure 1: Organic Burn-out and Glazing Profile for UNIMEC DM2700P/J105



**Table 1:** Sealing Time and Temperature Options (select one)

Sealing Parameter	Option A	Option B	Option C	Unit
Peak temperature	320	350	375	°C
Dwell time	10	5	2	minute

Glazing and sealing profiles may vary depending on the size and thermal properties of the components being processed. Clean, dry air atmosphere is preferred. Nitrogen atmosphere may require higher process temperatures or longer process times. Vacuum atmosphere should be avoided. For sealing Si wafer onto glass wafer, Namics recommends low CTE glass wafer such as Corning Pyrex<sup>®</sup> 7740 or SCHOTT AF 32<sup>®</sup> eco.

## VII. CONTACT INFORMATION

For more information on UNIMEC DM2700P/J105 and other Namics products contact:

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